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#### Taniuchi et al.

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# (54) MANUFACTURING METHOD OF STRUCTURE AND MANUFACTURING APPARATUS

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CPC . B32B 37/02; B29C 67/0051; B29C 67/0092; G03G 15/224

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# (57) ABSTRACT

A manufacturing method of a structure includes providing a stack of a first material layer to be a part of the structure and a restricting member wherein the first material layer is provided on a surface of the structure in the process of formation, and a part of the restricting member is provided on a surface of the first material layer in reverse of the surface of the structure in the process of formation, providing a support member between the restricting member and the surface of the structure in the process of formation, removing the restricting member, and providing a second material layer to be a part of the structure on surfaces of the first material layer and the support member exposed by removing the restricting member.

# 14 Claims, 7 Drawing Sheets

